## 3. DESIGN PARAMETERS

This section summarizes the design parameters of the NuMI.

# 3.1 Extraction and Primary beam



### 3.1.1 Proton Beam from Main Injector

Proton beam energy	120 GeV
Spill cycle time	1.87 sec
Bunch length	3-8 nsec
Batch length	84 bunches
Bunch spacing	18.8 nsec (53 MHz)
Emittance	40π mm-mr expected
	500π mm-mr max
Momentum spread	$2 \times 10^{-4}  \text{dp/p}  2\sigma \text{ expected}$
	$23 \times 10^{-3}  \text{Sp/p}  2\sigma  \text{max}$
NuMI spill (pbar operation)	5 batches x $84 + 4x3 = 432$ bunches = $8.14 \mu sec$
NuMI spill (no pbar operation)	6 batches x $84 + 5x3 = 519$ bunches = $9.78 \mu sec$
Maximum intensity	4 x 10 <sup>13</sup> ppp (protons/spill)
Total beam power	404 kW at maximum intensity

### 3.1.2 Extraction Method and Parameters

Extraction	Single turn
Method	3 traveling wave kicker magnets
Position stability (transport)	± 1 mm max
Beam size @ target	1 mm H x 1 mm V (σ)
Position stability @ target	$\pm 250 \mu$
Angular stability @ target	± 60 μ-radian max
Max DC beam loss (MI region)	10 <sup>-4</sup> at maximum intensity
Max DC beam loss (Carrier pipe)	10 <sup>-6</sup> at maximum intensity
Max DC beam loss (Pre-target)	10 <sup>-4</sup> at maximum intensity
Max beam loss - accident	5 spills at maximum intensity

### 3.1.3 Instrumentation

Profile monitors         Multi-wire SEM           Number of wires/plane         48 of 0.003" gold plated tungsten wires           Transport region         3 H + 3 V 1 mm wire spacing, motor-driven           Pre-Target         2 H + 2 V 0.5 mm wire spacing, motor-driven           Position reproducibility $< 50  \mu$ Intensity range $2.5 \times 10^{11}  \text{ppp to } 4 \times 10^{13}  \text{ppp}$ Channel signal/noise $100  \text{x}$ over intensity range           Material in beam $< 10^4  \text{loss}$ Beam position monitors         Cylindrical plate BPM           Transport region $6  \text{H} + 6  \text{V}$ Position resolution $0.2  \text{mm}  \text{rms}  \text{within} \pm 20  \text{mm for } 3 \times 10^{10}  \text{to}$ To sampling         One sample per batch           Calibration         Electronics charge injection inter-spill           Pre-target $2  \text{H} + 2  \text{V}$ Position resolution $0.05  \text{mm}  \text{rms}  \text{within} \pm 6  \text{mm for } 3 \times 10^{10}  \text{to}$ Sampling         One sample per batch           Calibration         Electronics charge injection inter-spill           Toroid intensity monitor         Electronics charge injection inter-spill           Toroid intensity monitor         3% absolute for $> 1 \times 10^{13}  \text{ppp}$ Stability	Dynamic range	$100 (= 4 \times 10^{13} / 4 \times 10^{11} \text{ protons/spill})$
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$ \begin{array}{c} Transport region \\ Pre-Target \\ Position reproducibility \\ So \mu \\ Intensity range \\ Channel signal/noise \\ Material in beam \\ Intensity range \\ Active for the producibility \\ Transport region \\ Intensity resolution \\ Position resolution \\ Sampling \\ Calibration \\ Pre-target \\ Position resolution \\ Sampling \\ Calibration \\ Intensity resolution \\ Sampling \\ Calibration \\ Intensity resolution \\ Sampling \\ Calibration \\ Electronics charge injection inter-spill \\ Pre-target \\ Position resolution \\ Sampling \\ Calibration \\ Electronics charge injection inter-spill \\ Pre-target \\ Position resolution \\ Sampling \\ Calibration \\ Electronics charge injection inter-spill \\ Pre-target \\ 2 H + 2 V \\ Position resolution \\ Sampling \\ Calibration \\ Electronics charge injection inter-spill \\ Calibration \\ Electronics charge injection inter-spill \\ Toroid intensity monitor \\ Intensity resolution \\ Sampling \\ Calibration \\ Sampling \\ Calibration \\ Electronics charge injection inter-spill \\ Toroid intensity monitor \\ Intensity resolution \\ 3\% absolute for > 1x10^{13} ppp \\ 30\% for > 3x10^{11} ppp \\ 30\% for > 3x10^{11} ppp \\ 30\% for > 3x10^{11} ppp \\ Accuracy \\ 2x10\% to 4x10^{13} ppp \\ Monitoring \\ High voltage status \\ Function \\ Sensitive to small localized losses \\ Total Loss Monitors \\ Carrier pipe region \\ Carrier pipe region \\ 1 of 430' long, 2 of 215' long \\ Pre-target region \\ Accuracy \\ 2x10\% to 4x10^{13} ppp \\ Monitoring \\ Radioactive source current inter-spill \\ Total Carrier pile region \\ Accuracy \\ 2x10\% to 4x10^{13} ppp \\ Monitoring \\ Radioactive source current inter-spill \\ Total Carrier pile region \\ Accuracy \\ 2x10\% to 4x10^{13} ppp \\ Monitoring \\ Radioactive source current inter-spill \\ Total Carrier pile region \\ Accuracy \\ 2x10\% to 4x10^{13} ppp \\ Monitoring \\ Radioactive source current inter-spill \\ Total Carrier pile region \\ Accuracy \\ 2x10\% to 4x10^{13} ppp \\ Monitoring \\ Total Carrier pile region \\ Accuracy \\ 2x10\% to 4x10^{13} ppp \\ Monitoring \\ Total Carrier pile region \\ Accuracy \\ 2x10\% to 4x10^{1$		
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Channel signal/noise       100x over intensity range         Material in beam       <10⁻⁴ loss		< 50 μ
Material in beam $<10^{-4}$ lossBeam position monitorsCylindrical plate BPMTransport region $6 \text{ H} + 6 \text{ V}$ Position resolution $0.2 \text{ mm}$ rms within $\pm 20 \text{ mm}$ for $3 \times 10^{10}$ to $9.5 \times 10^{10}$ protons/bunchIntensity resolution $\pm 3\%$ SamplingOne sample per batchCalibrationElectronics charge injection inter-spillPre-target $2 \text{ H} + 2 \text{ V}$ Position resolution $0.05 \text{ mm}$ rms within $\pm 6 \text{ mm}$ for $3 \times 10^{10}$ to $9.5 \times 10^{10}$ protons/bunchIntensity resolution $\pm 3\%$ SamplingOne sample per batchCalibrationElectronics charge injection inter-spillToroid intensity monitorThensity resolutionIntensity resolution $3\%$ absolute for $> 1 \times 10^{13}$ pppStability $<3\%$ at $> 1 \times 10^{13}$ pppStability $<3\%$ at $> 1 \times 10^{13}$ pppBeam loss monitors $35 \text{ Sealed gas ionization chambers}$ Accuracy $\pm 30\%$ at $2 \times 10^8$ pppDynamic range $2 \times 10^8$ to $4 \times 10^{13}$ pppMonitoringHigh voltage statusFunctionSensitive to small localized lossesTotal Loss Monitors $4 \text{ coax hose ionization, Ar-CO2 purged}$ Carrier pipe region $1 \text{ spanning the entire region}$ Accuracy $\pm 30\%$ at $2 \times 10^8$ ppDynamic range $2 \times 10^8$ to $4 \times 10^{13}$ pppMonitoringRadioactive source current inter-spill	·	
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Dynamic range $2x10^8$ to $4x10^{13}$ pppMonitoringRadioactive source current inter-spill		
Monitoring Radioactive source current inter-spill	<u> </u>	$2x10^8$ to $4x10^{13}$ ppp
	·	***
	Function	Sensitive to large losses

## 3.2 Neutrino Beam Devices

<u>Low Energy Beam</u> Peak at 3 GeV

## Baffle/Target Module

Module motion control	
Baffle	
composition	Graphite
aperture	5.4 mm H x 12 mm V
length	2 m
motion control	~10 cm H (manual drive)
cooling	Air or RAW under consideration
Target	
composition	Graphite segments (Poco ZXF-5Q)
length	47 of 20 mm long segments, 0.3mm spacing
density	$1.686 \pm 0.025 \text{ gm/cm}^3$
width	6.4 mm
height	18 mm
cooling	RAW cooling tubes top/bottom of fin
distance from horn 1	35 cm to Monte Carlo upstream end
motion control	~1 m Z insertion into Horn 1 (manual drive)

## Neutrino Horn 1 Module

Horn shape	Double Parabolic
Construction	Nickel plated aluminum inner conductor
	Anodized aluminum outer conductor
Minimum aperture field-free neck	9 mm radius
Inner conductor thickness	2 mm (min) – 4.5 mm (max at neck)
Outer conductor	11.75 inch I.D. 13.75 inch O.D.
Horn Length	300 cm focus region, 132 inches overall
Current	200 kA
Motion control	±1 cm H x ±1 cm V each end (motor drive)
Horn cooling	RAW spray, 30 gal/min

## Neutrino Horn 2 Module

Horn shape	Double Parabolic
------------	------------------

Construction	Nickel plated aluminum inner conductor
	Anodized aluminum outer conductor
Minimum aperture field-free neck	3.9 cm radius
Inner conductor thickness	3 mm (min) - 5 mm (max)
Outer conductor	29.134 inch I.D. 31.134 inch O.D.
Horn Length	300 cm focus region, 143 inches overall
Current	200 kA
Motion control	None
Distance from Horn 1	10 m (upstream end H1 to upstream end H2)
Horn cooling	RAW spray, 30 gal/min

### 3.3 Power Supply Systems

<u>Kicker Power Supply</u>: Single pulse forming network, drives 2 magnets in parallel

### Conventional Power Supplies Regulation requirements

Lam60	200 ppm
V100	400 ppm
HV101	65 ppm
V104	200 ppm
V105	60 ppm
V109	200 ppm
V110	55 ppm
Trims	0.1%
Quadrupoles	400 ppm

#### Horn Power Supply, current, voltage, Flat top regulation, Pulse width

The design criteria for the horn power supply and stripline are the current, current regulation, and pulse width. Horn 1 and horn 2 are connected in series with the power supply. The voltage is given at the output of the power supply. It is determined by the resistance and inductance of the strip line and horns. When we switched to single turn extraction, the power supply design was modified to give a pulse width of 2.6 msec. The section of stripline to the high energy horn 2 position was later eliminated, shortening the pulse length to 1.7 msec. The "flat-top" regulation is the allowed pulse to pulse variation.

Horn Power Supply: Series connection to Horn 1 and Horn 2

***	
Peak current	240k A
Operating current	200k A average ± 2.5%

### NuMI Technical Design Handbook

Current monitoring	0.4%
Operating voltage	800 V
Repeatability	± 1% pulse to pulse
Pulse width	~half-sine 1.7 ms @ base
Pulse period	1.9 sec

## Horn Stripline

Construction	30 cm x 10 cm Aluminum strips, 1 cm spacing
Resistance	$10$ μ $\Omega$ /m
Inductance	16 nH/m

# 3.4Hadron Decay Pipe

Size	1.98 m inner dia x 677.1 m long
Vacuum	<1 Torr
Upstream vacuum window	4.76 mm thick steel
Downstream vacuum window	6.35 mm thick steel

### 3.5Hadron Absorber

Primary beam size at Absorber (target out)	5.4 cm H x 7.9 cm V (1 σ)	
Primary beam size at Absorber	29 cm (rms)	
(target in)		
Beam power - normal	64 kW	
	(82% primary protons, 18% secondaries)	
Beam power - accident	404 kW	
Accident condition	1 hour (1900 pulses) mis-targeted primary proton	
Absorber core	8 aluminum modules + 10 steel CCSS layers	
Aluminum modules	1.29 m H x 1.29 m V x 30 cm Z	
	RAW cooled	
Steel CCSS layers	1.29 m H x 1.29 m V x 23 cm Z	
Max temperature - normal	60 °C in aluminum modules 3 and 4	
	270 °C in steel module 1	
Max temperature - accident	160 °C in aluminum modules 3 and 4	
	800 °C in steel module 1	

### 3.6 Neutrino Beam Monitoring

The NuMI beam monitoring system consists of 1 plane of Hadron Monitors (DHM) downstream of the decay pipe and upstream of the Hadron Absorber, 3 planes of Muon monitors located in the Hadron Absorber enclosure (Muon Alcove 0), Muon Alcove 1 and Muon Alcove 2. The peak charged particle fluxes per spill in the various monitoring locations, assuming  $4x10^{13}$  protons per spill.

Station	Maximum Flux/spill
DHM	$2.5 \times 10^9 / \text{cm}^2$
Alcove 0	$3.2 \times 10^7 \text{/cm}^2$
Alcove 1	$1.7 \times 10^7 / \text{cm}^2$
Alcove 2	$0.22 \times 10^7 / \text{cm}^2$

The following table gives the fluxes per spill, and the associated radiation doses per year, expected in the monitoring locations, as a function of particle type. Doses calculated by translating fluxes to Sieverts and then to rads, taking into account spectral information

Station	Particle	Flux (/cm <sup>2</sup> /spill)	Dose/year(Rads)
DHM	protons	$1.3x10^9$	13Grad
DHM	other charged hadrons	$2.0x10^9$	0.3Grad
DHM	neutrons	$3.5 \times 10^9$	0.2Grad
Alcove 0	neutrons	$10.0 \text{x} 10^7$	10Mrad
Alcove 0	muons	$1.30 \times 10^7$	5Mrad
Alcove 1	muons	$0.40 \times 10^7$	1.8Mrad
Alcove 1	neutrons	$0.04 \times 10^7$	0.1Mrad
Alcove 2	muons	$0.14 \times 10^7$	0.6Mrad
Alcove 2	neutrons	$0.04 \times 10^7$	0.04Mrad

## **3.7Alignment Systems**

Alignment tolerances for Low Energy beam

Beam position at target	± 0.45 mm
Beam angle at target	± 0.7 mrad
Target position - each end	± 0.5 mm
Horn 1 position - each end	± 0.5 mm
Horn 2 position - each end	± 0.5 mm
Decay pipe position	± 20 mm
Downstream Hadron monitor	± 25 mm
Muon Monitors	± 25 mm
Near Detector	± 25 mm
Far Detector	± 12 mm

### 3.8Water, Vacuum & Gas Systems

CUB = Central Utility Building

CW = Chilled Water

LCW = Low Conductivity Water

PW = Pond Water

RAW = Radioactive Water

SB = Service Building

### Power dissipation

Beam transport magnets	628 kW
MI-62 LCW system	700/1200 (kW nominal/max) to MI Pond G
MINOS LCW system	108/200 (kW nominal/max) to MINOS SB CW
Absorber RAW	60/200 (kW nominal/max) to MINOS SB PW
Decay pipe RAW	150/200 (kW nominal/max) to CUB CW (1/2)
	and MINOS SB CW (1/2)
Target RAW	10/25 (kW nominal/max) to MI62 LCW
Horn 1 RAW	40/200 (kW nominal/max) to CUB CW
Horn 2 RAW	10/50 (kW nominal/max) to CUB CW

### Vacuum

Main Injector extraction region	10 <sup>-8</sup> Torr
Primary beam transport vacuum	10 <sup>-6</sup> Torr
Carrier pipe	
Diameter	12"
Vacuum maximum	10 <sup>-5</sup> Torr
Vacuum expected	7 x 10 <sup>-7</sup> Torr maximum
Hadron Decay Pipe vacuum	0.1 to 1 Torr

### Carrier Pipe size, vacuum

The 430' long carrier pipe diameter was determined by an informal cost/benefit analysis. The pipe size is much larger than all magnet apertures, however the consequence of a significant beam loss in the carrier pipe region is severe. The maximum vacuum level is determined by the ground water requirement during normal operation due to interactions with the residual gas. The

expected vacuum level is achieved in the middle of the carrier pipe by 3 large ion pumps located at each end of the carrier pipe.

# 3.9 Installation & Integration

Controls	Power supplies, instrumentation, vacuum, water, beam position & intensity, beam permit, beam
	loss budget monitor
Beam permit System	Power suppy current & voltage nominal
	Multi-wire fully inserted/extracted
	Loss monitors nominal
	Vacuum valves open
	Previous Main Injector spill transport nominal
	BPM positions nominal
	Target Budal monitor nominal

# 3.10 Commissioning

Beam intensity	$5 \times 10^{12} \text{ ppp}$
Near detector fiducial mass	0.015 kt (40 planes tgt region, 75 cm radius)
Near Detector exposure	$2 \times 10^{-6} \text{ kt-yr/day}$